#### SUMMARY OF INTERVIEW

#### Attendees, Date and Type of Interview

The interview was conducted on 9/11/2008 and attended by Examiner Kelly Stouffer and Applicant's Representatives, Andrew Merickel and Kurt Meinz, both of Knobbe Martens Olson & Bear.

# Exhibits and/or Demonstrations

None.

### Identification of Claims Discussed

Claim 1.

# Identification of Prior Art Discussed

Dillon, Surface Science 322 (1995), 230-242.

Penneck et al., U.S. Patent No. 4,985,313.

#### Proposed Amendments

None.

#### Principal Arguments and Other Matters

Applicant's Representatives discussed how Dillon's disclosure related to deposition coverage on pages 239-241 refers to surface area coverage, not thickness.

Applicant's Representatives also discussed the distinctions between the process disclosed in Dillon and Applicant's process. Applicant's Representatives noted in particular that the pending claims recite the use of atomic oxygen, while Dillon does not use activated species.

### Results of Interview

Applicant's Representatives agreed to file a response to the previous Office Action consistent with the discussion